



[www.nnt2017.org](http://www.nnt2017.org)

# NNT 2017

November 08 ~ 10, 2017 CECO, Changwon, Gyeongnam, Korea

You are cordially invited to participate in the 16<sup>th</sup> International Conference on Nanoimprint and Nano Nanoprint Technology, NNT 2017, to be held in CECO, Changwon, Korea, from November 8 to 10, 2017. It will provide a perfect opportunity to get the most up-to-date information and recent trends in the nanoscale science and technology through lectures of world-famous scholars and presentations of latest nanotechnology research results. It has been held annually from 2002 for exchanges and expansion of the latest nanoimprint and nanoprint technology research results. Especially, this year it will be held with NANOPIA 2017 that is meaningful nanotechnology conference in Korea. It will be a great platform for sharing the most recent achievements and collaborations. We cordially invite you to submit abstract for oral and poster presentations. We hope to see you in Korea in 2017.

The 16<sup>th</sup> International Conference  
on Nanoimprint and Nanoprint  
Technology

## Important Dates

- **Abstract Submission:**  
July 1~August 15, 2017
- **Notification of Acceptance:**  
August 31, 2017
- **Pre-registration Due:**  
September 25, 2017

## Committee

### Conference Chair

Eung-Sug Lee (KIMM, Korea)

### Conference Co-Chair

Myung Yung Jeong (Pusan Nat'l Univ., Korea)

Shinill Kang (Yonsei Univ., Korea)

### Program Chair

Heon Lee (Korea Univ., Korea)

### Program Co-Chair

Jae Jong Lee (KIMM, Korea)

### Cooperation Chair

Hak Joo Lee

(Center for Advanced Meta-Materials, Korea)

### Cooperation Co-Chair

Jeongdai Jo (KIMM, Korea)

Nak-Kyu Lee (KITECH, Korea)

### International Steering Committee

Stephen Y. Chou

(Princeton Univ., USA)

Lars Montelius

(INL, Portugal)

Helmut Schift

(PSI Villigen, Switzerland)

Yoshihiko Hirai

(Osaka Prefecture University, Japan)

Eung-Sug Lee

(KIMM, Korea)

## Program Topics

### Stamps, materials and processes for nanoimprinting and printing

-Chair: Gun Young Jung (GIST, Korea)

### Application :

### Nanodevices and nanoelectronics

-Chair: Jae Jong Lee (KIMM, Korea)

### Meta Materials

-Chair: Jun Ho Jeong (KIMM, Korea)

### 3D and 4D Printings

-Chair: Myung Woon Moon (KIST, Korea)

## Plenary Speakers

Sungwoo Hwang (SAIT, Korea)

Cherie Kagan (UPenn, USA)

## Organized by

Korea Institute of Machinery and Materials

National Center for Optically assisted ultra high precision Mechanical Systems

BK21+ Nano Integrated Cogno-Mechatronics Engineering

Center for Creative Materials and Components, BK21 Plus Project, Korea University

Center for Advanced Meta-Materials

The Korean Society of Manufacturing Process Engineers

## Sponsored by

Korea Tourism Organization

Gyeongnam Convention & Visitors Bureau